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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

Takuji IKEDA, et al.

SERIAL NO: 10/579,720

FILED: May 17, 2006

FOR: HIGH SILICA CDS-1 ZEOLITE



GROUP: 1755

ATTENTION:
FILING RECEIPT CORRECTIONS

REQUEST FOR CORRECTED OFFICIAL FILING RECEIPT

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Sir:

The Patent Office is requested to provide a corrected Official Filing Receipt for the following.

PLEASE NOTE THAT THE ASSIGNMENT FOR PUBLISHED PATENT APPLICATION DATA IS INCORRECT. IT SHOULD READ AS FOLLOWS:

NATIONAL INSTITUTE OF ADVANCED INDUSTRIAL SCIENCE AND TECHNOLOGY, TOKYO, JAPAN

No fees are required. If you have any questions, please do not hesitate to contact us.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.
Norman F. Oblon

A handwritten signature in black ink, appearing to read "Paul J. Killos", is written over a solid horizontal line.

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APPL NO.	FILING OR 371(c) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	TOT CLMS	IND CLMS
10/579,720	05/17/2006	1755	2900	291165US0PCT	43	6

CONFIRMATION NO. 3490

22850
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 1940 DUKE STREET
 ALEXANDRIA, VA 22314

CORRECTED FILING RECEIPT



OC000000024921080

Date Mailed: 07/19/2007

Receipt is acknowledged of this nonprovisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

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RECEIVED: 7/23/07
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DOCKETING DEPT
 Initials/Date Docketed: MP7/24/07
 Type of Resp(s): _____
 Due Date(s): _____

Assignment For Published Patent Application

NATIONAL INSTITUTE OF ADVANCED INDUSTRIAL SCIENCE AND TECHNOLOGY, Tokyo,
JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 22850.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/17106 11/17/2004

Foreign Applications

JAPAN 2003-386809 11/17/2003
 JAPAN 2003-387299 11/17/2003
 JAPAN 2003-435651 12/26/2003

If Required, Foreign Filing License Granted: 02/03/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is US10/579,720

Projected Publication Date: Not Applicable

Non-Publication Request: No

Early Publication Request: No

Title

High silica cds-1 zeolite

Preliminary Class

423

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Title 37, Code of Federal Regulations, 5.11 & 5.15

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